Ĺ	Hits	Search Text	DB	Time stamp
Number				
2	_ 0	5482612.pn. and (polymer or LCP)	USPAT	2003/11/10 09:50
1	1	5482612.pn.	USPAT	2003/11/10
2	1004	//limid add awastales add palymon) or	USPAT	09:50
3	1224	((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and semiconductor	USPAI	13:40
4	961	(((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/10
	}	LCP or Vectra or Xydar) and semiconductor) and (substrate or wafer)		09:57
5	861	((((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/10
1		LCP or Vectra or Xydar) and semiconductor) and (substrate or wafer))		09:57
		and @ay<=2000		
6	278	(((((liquid adj crystal\$5 adj polymer) or LCP or Vectra or Xydar) and	USPAT	2003/11/10
1		semiconductor) and (substrate or wafer))		
7	496	and @ay<=2000) and plasma ((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/10
	150	LCP or Vectra or Xydar) and plasma and]	10:26
8	437	(chamber or apparatus) (((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/10
	127	LCP or Vectra or Xydar) and plasma and)	10:25
9	312	(chamber or apparatus)) and @ay<=2000 ((((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/10
	314	LCP or Vectra or Xydar) and plasma and	JOIN	10:26
		(chamber or apparatus)) and @ay<=2000) and (aluminum or alumina)		
10	175	(((((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/10
		LCP or Vectra or Xydar) and plasma and (chamber or apparatus)) and @ay<=2000)		10:27
1		and (aluminum or alumina)) and		
11	496	semiconductor ((liquid adj (crystal or crystalline) adj	USPAT	2003/11/10
	490	polymer) or LCP or Vectra or Xydar) and	OSFAI	10:45
12	367	plasma and (chamber or apparatus) (((liquid adj (crystal or crystalline)	USPAT	2003/11/10
12	367	adj polymer) or LCP or Vectra or Xydar)	USPAI	10:26
		and plasma and (chamber or apparatus))		
13	175	and (aluminum or alumina) (((((liquid adj (crystal or crystalline)	USPAT	2003/11/10
		adj polymer) or LCP or Vectra or Xydar) and plasma and (chamber or apparatus))		10:30
		and (aluminum or alumina)) and		
15	0	semiconductor and @ay<=2000 (Vectra adj IMP) and (liquid adj (crystal	USPAT	2003/11/10
13		or crystalline) adj (polymer or	USPAI	10:31
16	9	polymeric)) Vectra adj IMP	iic D v a	2003/11/10
10	9	vectia auj imp	USPAT	10:31
17	407	((liquid adj (crystal or crystalline) adj	USPAT	2003/11/10
		polymer) or LCP or Vectra or Xydar) same (chamber or apparatus)	}	10:32
18	49	(((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar)	USPAT	2003/11/10
		same (chamber or apparatus)) and plasma		ļ
19	235	((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar) and	US-PGPUB; EPO; JPO;	2003/11/10
		plasma and (chamber or apparatus)	DERWENT	10.40
20	31	(((liquid adj (crystal or crystalline) adj polymer) or LCP or Vectra or Xydar)	US-PGPUB; EPO; JPO;	2003/11/10
ļ		and plasma and (chamber or apparatus))	DERWENT	,,
21	4	and @ay<=2000 "0433778"	US-PGPUB;	2003/11/10
	4	0.155776	EPO; JPO;	11:08
22	0	"0433778"	DERWENT EPO	2003/11/10
[_	0.100770		11:08
23	868	Bayer.in.	EPO	2003/11/10 11:08
	l		L	1 - 1 - 0 0

Search History 11/10/03 5:24:50 PM Page 1

		<u>.</u>		
24	10	Bayer.in. and Hermann	EPO	2003/11/10 11:16
25	4801	plasma and ((chamber or apparatus) same (LCP or polymer))	USPAT	2003/11/10
26	2378	plasma and ((chamber or apparatus) with (LCP or polymer))	USPAT	2003/11/10
27	1036	(plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor	USPAT	2003/11/10 11:17
28	950	((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000	USPAT	2003/11/10 11:17
29	730		USPAT	2003/11/10
30	449	(((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating))	USPAT	2003/11/10 16:40
31	327	<pre>((((plasma and ((chamber or apparatus) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating))) and (aluminum or alumina)</pre>	USPAT	2003/11/10 11:19
32	314		USPAT	2003/11/10 11:19
33	1		USPAT	2003/11/10 13:18
34	10	("4336276" "4505945" "5019686" "5144110" "5206259" "5216092" "5296542" "5434210" "5530050" "5834064").PN.	USPAT	2003/11/10 13:35
35	113		USPAT	2003/11/10 16:41
37	109		USPAT	2003/11/10 16:29
38	38	,	USPAT	2003/11/10 14:08
39	31	((((plasma and (chamber or apparatus))) with (LCP or polymer))) and semiconductor) and @ay<=2000) and ((polymer or LCP) with (wall or coat or coating))) and filler	USPAT	2003/11/10 16:39
40	1663		USPAT	2003/11/10 16:41
41	428	l l	USPAT	2003/11/10 16:41
42	39		USPAT	2003/11/10 16:41
_	1168	((liquid adj crystal\$5 adj polymer) or	USPAT	2003/11/10
_	312	LCP) and semiconductor (((liquid adj crystal\$5 adj polymer) or LCP) and semiconductor) and plasma	USPAT	09:55 2003/11/03 16:09

_	302	Tritter and the second postimor, or	USPAT	2003/11/03
		LCP) and semiconductor) and plasma) and		16:09
		(substrate or wafer)		
-	274		USPAT	2003/11/03
		LCP) and semiconductor) and plasma) and		16:09
	240	@ay<=2000		
-	240		USPAT	2003/11/03
		LCP) and semiconductor) and plasma) and	f	16:14
_	226	@ay<=2000) and (aluminum or alumina)		
	220		USPAT	2003/11/03
		or LCP) and semiconductor) and plasma) and @ay<=2000) and (aluminum or alumina))		16:21
		and edy(=2000) and (aluminum or alumina))		
		and (chamber or apparatus or (focus adj ring) or plate or pedestal)		
_	36	((((((liquid adj crystal\$5 adj polymer)		10000 (11 (00
	1	or LCP) and semiconductor) and plasma)	USPAT	2003/11/03
		and @ay<=2000) and (aluminum or alumina))		16:48
		and (((liquid adj crystal\$5 adj polymer)		
		or LCP) same (chamber or apparatus or		į
		(focus add ming) or minter or apparatus or		
_	965	(focus adj ring) or plate or pedestal))		
	903		USPAT	2003/11/03
		LCP) same (chamber or apparatus or (focus		16:48
_	57	adj ring) or plate or pedestal))		
1	5/		USPAT	2003/11/03
f		LCP) same (chamber or apparatus or (focus		16:51
		adj ring) or plate or pedestal))) and		
	52	semiconductor and (etch or etching)	1	İ
_	52		USPAT	2003/11/03
		LCP) same (chamber or apparatus or (focus		16:51
		adj ring) or plate or pedestal))) and		
		semiconductor and (etch or etching)) and		
_	E 1 0 1	@ay<=2000		
_	5181	((liquid adj (crystal or crystalline) adj	USPAT	2003/11/05
_	2445	polymer) or LCD) and (etch or etching)		09:58
_	2445	(((liquid adj (crystal or crystalline)	USPAT	2003/11/05
		adj polymer) or LCD) and (etch or		09:58
	2102	etching)) and plasma		
-	2182	1 111 The state of of the contraction	USPAT	2003/11/05
		adj polymer) or LCD) and (etch or		09:58
1_	895	etching)) and plasma) and @ay<=2000		
	095	(((((liquid adj (crystal or crystalline)	USPAT	2003/11/05
		adj polymer) or LCD) and (etch or		09:51
		etching)) and plasma) and @ay<=2000) and		
_	20	wall		
1	38		USPAT	2003/11/05
		adj polymer) or LCD) and (etch or		09:52
		etching)) and plasma) and @ay<=2000) and		
		((wall or coating) with (LCP or (liquid		
	1	adj (crystal or crystalline) adj		
_	928	polymer)))		
	928	((liquid adj (crystal or crystalline) adj	USPAT	2003/11/05
_	308	polymer) or LCP) and (etch or etching)		09:58
1	308		USPAT	2003/11/05
		adj polymer) or LCP) and (etch or		09:58
]_	277	etching)) and plasma	****	1
_	211	((((liquid adj (crystal or crystalline)	USPAT	2003/11/05
1		adj polymer) or LCP) and (etch or		09:58
_	100	etching)) and plasma) and @ay<=2000		
İ	48	(((((liquid adj (crystal or crystalline)	USPAT	2003/11/05
		adj polymer) or LCP) and (etch or		11:34
	'	etching)) and plasma) and @ay<=2000) and]
1	.	((wall or coating) same (LCP or (liquid		1
[adj (crystal or crystalline) adj]
_		polymer)))		
_	1	6326307.pn.	USPAT	2003/11/05
		E992245 mm		11:35
	2	5882245.pn. or 5488603.pn.	USPAT	2003/11/05
	L			12:52